Total Pages: 3

		CMDE/M-20 2022			
	Ι	Paper–EL-25(iv) Option–(iv)			
Tin	ne Al	llowed: 3 Hours] [Maximum Marks: 7	5		
No	te:	Attempt five questions in all, selecting at least one question from each Unit. Question No. 1 is compulsory. All questions carry equal marks.	s		
Compulsory Question					
1.	(a)	What is FINFET?	3		
	(b)	What is parameter extraction in the device modeling and simulation?	e 3		
	(c)	What are the differences between empirical mode and analytical models?	al 3		
	(d)	What is gate coupling?	3		
	(e)	What is a quantum well? What are it applications?	s 3		
		UNIT-I			
2.	(a)	What are the various approaches used in scaling of MOSFET devices?	g 8		
20 2	2/K/	/970 P. T. O			

Roll No.

		effects in detail.	7
3.	(a)	Write a short notes on ITRS roadmap.	8
	(b)	What is Moore's law? What is its role in to development of semiconductor industry?	he 7
		UNIT-II	
4.		ite a short note on numerical simulation. Wh current simulation challenges?	at 15
5.		at is the need of semiconductor device modelin at are key elements of physical device simulatio	
		UNIT-III	
6.	(a)	What is meaning of technology nodes?	9
	(b)	What are technological challenges to the MOSFET scaling?	he 6
7.	(a)	Write a detailed note on Silvaco's ATLA simulation tool.	AS
	(b)	What is Billistic transport? Why is it importation the study of scaling of devices?	int 7
202	22/K/	/970 2	

(b) Describe the velocity overshoot and high field

UNIT-IV

- 8. (a) What are RTDs? Explain their structure and working.
 - (b) Describe the working of single electron transistorwith the help of circuit diagram.
- 9. (a) What is carrier confinement? Why is it important in case of low dimensional structures? 7
 - (b) Write a short note on quantum wires and quantum dots.